Docket No.

220110US2S

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF:

Akira HOKAZONO

SERIAL NO:

NEW APPLICATION

Herewith

GAU:

EXAMINER:

FILED: FOR:

SEMICONDUCTOR DEVICE HAVING ACTIVE REGIONS CONNECTED TOGETHER BY INTERCONNECT LAYER

AND METHOD OF MANUFACTURE THEREOF

INFORMATION DISCLOSURE STATEMENT UNDER 37 CFR 1.97

ASSISTANT COMMISSIONER FOR PATENTS WASHINGTON, D.C. 20231

SIR:

Applicant(s) wish to disclose the following information.

REFERENCES

- The applicant(s) wish to make of record the references listed on the attached form PTO-1449. Copies of the listed references are attached, where required, as are either statements of relevancy or any readily available English translations of pertinent portions of any non-English language references.
- ☐ A check is attached in the amount required under 37 CFR §1.17(p).

RELATED CASES

- Attached is a list of applicant's pending application(s) or issued patent(s) which may be related to the present application. A copy of the patent(s), together with a copy of the claims and drawings of the pending application(s) is attached along with PTO 1449.
- ☐ A check is attached in the amount required under 37 CFR §1.17(p).

CERTIFICATION

- Each item of information contained in this information disclosure statement was first cited in any communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of this statement.
- No item of information contained in this information disclosure statement was cited in a communication from a foreign patent office in a counterpart foreign application or, to the knowledge of the undersigned, having made reasonable inquiry, was known to any individual designated in 37 CFR §1.56(c) more than three months prior to the filing of this statement.

DEPOSIT ACCOUNT

Please charge any additional fees for the papers being filed herewith and for which no check is enclosed herewith, or credit any overpayment to deposit account number 15-0030. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

OBLON, SPIVAK, McCLELLAND, MAIER & NEUSTADT, P.C.

Marvin J. Spivak

Registration No.

24,913

C. Irvin McClelland Registration Number 21,124



Tel. (703) 413-3000 Fax. (703) 413-2220 (OSMMN 10/01)

DOCKET NO.: 220110US2S page_1_ of_1_

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STATEMENT OF RELEVANCY

Reference AO (2000-114262) on Form PTO-1449:

To realize the elevated S/D formation solid phrase epitaxy process is used, where deposited film is left on the STI to form the Local Interconnect (LI).

